



INFORMATION DISCLOSURE CITATION <i>(Use several sheets if necessary)</i>		Docket Number (Optional) <b>CRNG.053</b>	Application Number <b>UNKNOWN</b>
		Applicant(s) <b>Xinghua Li et al.</b>	
		Filing Date <b>March 9, 2004</b>	Group Art Unit <b>UNKNOWN</b>
*EXAMINER INITIAL	OTHER DOCUMENTS <i>(Including Author, Title, Date, Pertinent Pages, Etc.)</i>		
<i>AE</i>	M.H.R. Hutchinson, T. Ditzmire, E. Springate, J.W.G. Tisch, Y.L. Shao, M.B. Mason, N. Hay and J.P. Marangos; "High-intensity lasers: interactions with atoms, molecules and clusters"; The Royal Society, 1998, pp. 297-315.		
<i>AC</i>	A. Streletsov, J.F. Schroeder, R.M. Morena, K.P. Reddy and M.P. Powley; "Hermetically Sealed Glass Package and Method of Fabrication"; Serial Number 10/414,653 filed April 16, 2003.		
EXAMINER	DATE CONSIDERED		<i>9/24/06</i>
*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.			

FORM PTO-1449 (MODIFIED)	ATTORNEY DOCKET NO.	SERIAL NO.
<p style="text-align: center;"><b>LIST OF PATENTS AND PUBLICATIONS</b></p> <p><b>FOR APPLICANT'S INFORMATION</b></p> <p><b>DISCLOSURE STATEMENT</b></p> <p style="text-align: right;">NOV 18 2004 USPTO</p>	SP04-012	10/796,752
	APPLICANT Xinghua Li, et al	
	FILING DATE	3-9-04

~~DATE~~ REFERENCE DESIGNATION ~~MADE~~

## U.S. PATENT DOCUMENTS

## FOREIGN PATENT DOCUMENTS

**OTHER ART (Including Author, Title, Date, Pertinent Pages, etc.)**

	<b>AA</b> C. Schaffer, et al., "Structural Changes Induced in Transparent Materials with Ultrashort Laser Pulses", Digest of Conference on Lasers and Electro Optics (CLEO) 2000 OSA Technical Digest Series

**EXAMINER:**

M. Alexandra Elve

**DATE CONSIDERED:**

9/24/06

**EXAMINER:** Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.